

# ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

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<b>Title of Invention</b>	TWO-MASK PROCESS FOR METAL-INSULATOR-METAL CAPACITORS AND SINGLE MASK PROCESS FOR THIN FILM RESISTORS
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Application Number :

Confirmation Number:

First Named Applicant: Glenn Biery

Attorney Docket Number: FIS920030147US1

Art Unit:

Examiner:

Search string: ( 6278147 or 6387754 or 6413815 or 6451667 or 6461914 or 6468858 or 6528366 or 6580111 ).pn

## US Patent Documents

**Note: Applicant is not required to submit a paper copy of cited US Patent Documents**

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	1	6278147	2001-08-21	Dalton, et al.			
	2	6387754	2002-05-14	Dalton, et al.			
	3	6413815	2002-07-02	Lai, et al.			
	4	6451667	2002-09-17	Ning			
	5	6461914	2002-10-08	Roberts, et al.			
	6	6468858	2002-10-22	Lou			
	7	6528366	2003-03-04	Tu, et al.			
	8	6580111	2003-06-17	Kim, et al.			

## Signature

Examiner Name	Date